

IN THE SPECIFICATION:

Please amend the paragraph beginning on page 15, line 21, as follows:

--So, in the structure shown in Fig. 3, the first storage capacitor electrode 2d is separately formed isolated from the source electrode 2c (the first semiconductor layer). Therefore, the first storage capacitor electrode 2d is electrically connected to an island-like electrode 65 via another contact hole 51j formed on the first interlayer insulating film 51. Thus, the island-like electrode 65 is connected to the pixel electrode 7 via a contact hole 52k formed on the second interlayer insulating film 52. It will be noted that an ~~island-line~~island-like electrode 65 is simultaneously formed when the island-electrode 61 is formed.